

## CDF Pixel Chip

Assume chip has a 18 x 160 array of pixels each 50 x 400  $\mu$ .

Active area = 7.2 mm wide x 8.0 mm high.

Chip area with overhead for periphery logic = 7.4 x 11 mm = 81.4 mm<sup>2</sup>.

Chips to be fabricated on 200 mm (8") diameter wafers.

Wafer area = 31416 mm<sup>2</sup>

Estimate 15% of area lost to edge, streets and PCMs.

Useable area = 26700 mm<sup>2</sup>

Chips/wafer = 26700/82 = 325

Assume 60% yield

Good chips/wafer = 195

## **Fabrication Costs and Schedule**

First prototype using basic core and CDF periphery:

18 columns x 16 rows = 7.4 mm x 3.8 mm =  
28.1 mm<sup>2</sup>

30 mm<sup>2</sup> x \$1250/mm = \$37500

Design – 6 months

Fabrication – 2.5 months

Test - 2 months by designers and more by DAQ  
personnel

Second prototype

\$37500

Design – 2 months

Fabrication – 2.5 months

Test – ???

Engineering run – full size chip (could be production  
if lucky)

\$161,000 for 10 wafers

\$31,700 for 10 more wafers

Approximately 2000 good chips from 10 wafers

Design – 2 months

Fabrication – 2.5 months

## **Current R&D Plan**

Complete testing of Pre-FPIX2\_T

Test Pre-FPIX2\_I in July and August

Submit FPIX2???? at the beginning of August.

Includes serial interface and programming  
DACs to reduce external component count  
and chip pad count.

Submit FPIX3 with DAQ interface for BTEV by  
April 1, 2001